

On the morphological instability of silicon/silicon dioxide nanowires

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A typing error unfortunately lead to a wrong expression on page 1406 in the paragraph between equations (1) and (2). Instead of

$$\lambda = \frac{2\pi}{\kappa} \approx 4.5082a$$

it should read

$$\lambda = \frac{2\pi}{\kappa} \approx 4.508 \cdot 2a.$$

We thank Prof. Glaeser (University of California, Berkeley) for pointing out this error.

The online version of the original article can be found under
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